

Supporting Information:

Enhanced ferroelectricity in $\text{NaNbO}_3\text{-LaCoO}_3\text{:Mn}$ epitaxial thin film

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Experimental section:

Target preparation and thin film growth:

Na_2CO_3 , Nb_2O_5 , and MnO_2 powders were mixed to prepare $\text{NaNb}_{0.95}\text{Mn}_{0.05}\text{O}_3$ ceramic. Na_2CO_3 and Nb_2O_5 powders were mixed to prepare NaNbO_3 ceramic. Then calcined these powders at 850°C for 3h. Next, the powders were pressed into 60 mm diameter disk at 30MPa using polyvinyl alcohol (PVA) as the binder and sintered at 750°C for 2 h. For the LaCoO_3 target, La_2O_3 and Co_3O_4 were mixed and calcined at 1200°C for 10h. Then these powders were also pressed into 60 mm diameter disk at 30MPa using PVA and sintered at 1000°C for 3 h.

The epitaxial thin film was deposited by RF sputtering on (001) LaAlO_3 substrates at 600°C . The pressure is 1.5 Pa with Ar and O_2 . By controlling the sputtering power, we can get thin films with different La and Co contents. And the optimal power is 12W of LaCoO_3 target and 112W of $\text{NaNbO}_3\text{:Mn}$ target. Before the deposition of the NNO thin film, a buffer layer of SrRuO_3 (SRO) was first sputtered at 680°C as the bottom electrode. And the pressure is also 1.5 Pa with Ar and O_2 . Mask with $100\mu\text{m}$ holes was used to deposited Pt top electrode.

Characterization:

The θ - 2θ X-ray diffraction (XRD) at room temperature, phi scan, and reciprocal space mapping (RSM) were collected at the diffuse X-ray scattering station of the Beijing Synchrotron Radiation Facility (1W1A beamline). The high temperature XRD was measured by a powder diffractometer (X'Pert(III), PANalytical, $\lambda = 1.5406 \text{ \AA}$). The rocking curve was collected by a single crystal diffractometer (Bruker AXS GmbH).

The ferroelectric P - E hysteresis loops, I - V loops, J - V curves, and fatigue tests were measured using a ferroelectric tester (TF-Analyzer 1000, aixACCT, Germany). The dielectric constant as a function of temperature was collected by an impedance analyzer (4294, Hewlett Packard) connected with a high temperature probe system (HFS600E-PB2, Linkam, UK).

The X-ray absorption spectra were measured at the photoelectron spectroscopy

station of the Beijing Synchrotron Radiation Facility (4B9B beamline). The X-ray photoelectron spectroscopy (XPS) were collected using a spectroscopy spectrometer (Thermo ESCALAB 250XI).

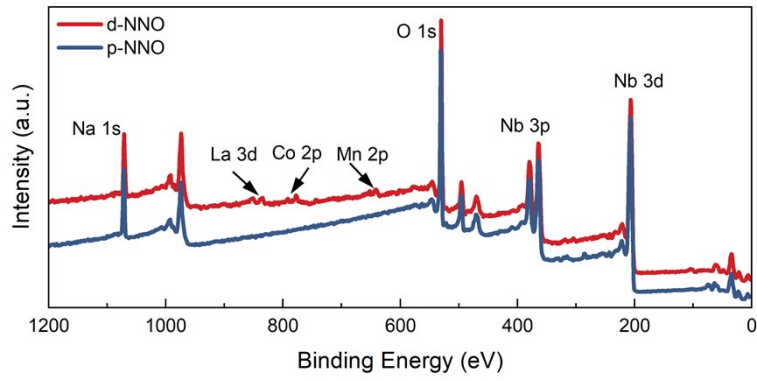


Fig.S1 XPS of the p-NNO and d-NNO thin films with all the major peaks indicated.

Compared with the p-NNO, the peaks appeared at 641 and 652, 780 and 792, 836 and 850 eV in the d-NNO thin film are ascribed to the Mn 2p, Co 2p and La 3d^{1,2,3}, proving the presence of these elements in d-NNO thin film.

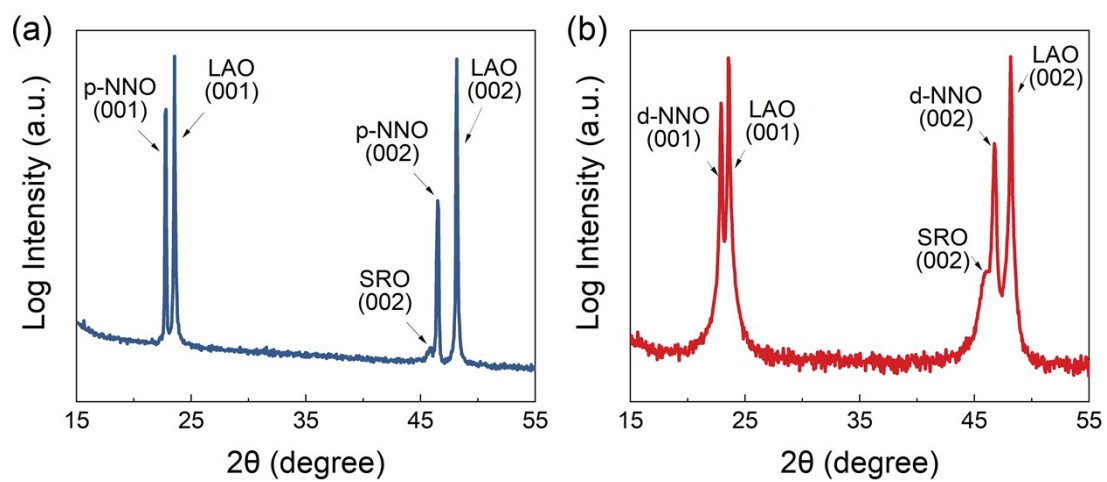


Fig.S2 Out-of-plane XRD patterns of the p-NNO (a) and d-NNO (b) thin films.

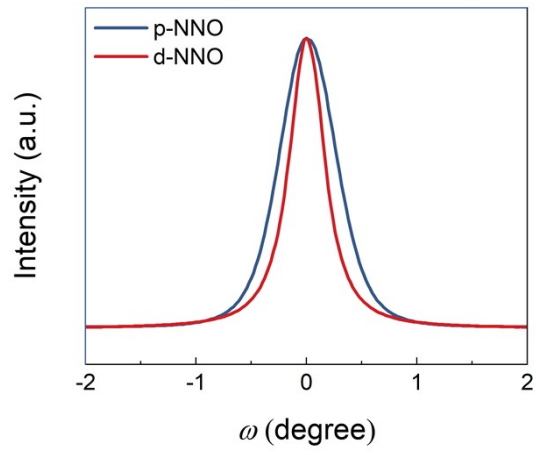


Fig.S3 Rocking curves of p-NNO and d-NNO thin films.

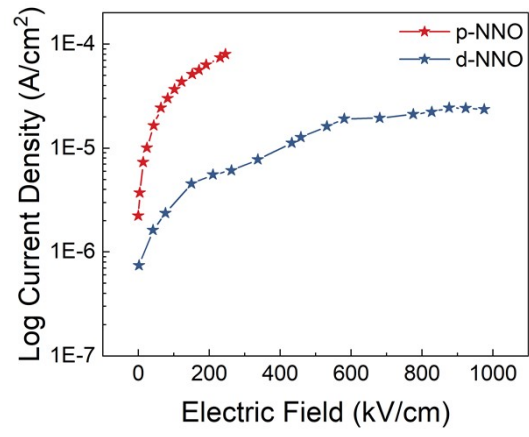


Fig.S4 Leakage current density as a function of electric field for p-NNO and d-NNO thin films.

References:

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